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Author Correction: Generation and characterization of ultrathin free-flowing liquid sheets

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The original version of this Article contained an error in Equation (1), which incorrectly read “Absorbance = $\log\left(\frac{I_0}{I}\right) = \epsilon lh$ ”.

The correct version reads “Absorbance = $\log\left(\frac{I_0}{I}\right) = \epsilon lc$ ”. This has been corrected in both the PDF and HTML versions of the Article.

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